## Supporting Information

## Microwave Initiated Facile Formation of Ni<sub>3</sub>Se<sub>4</sub> Nanoassemblies for Enhanced and Stable Water Splitting in Neutral and Alkaline Media

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## **Reagents and Instruments**

Selenium metal powder and sodium borohydride were procured from Sigma-Aldrich. Commercial RuO<sub>2</sub> catalyst was obtained from Alfa Aesar. Hg/HgO reference electrode, Pt-foil counter electrodes were purchased from CH Instruments Pvt. Ltd. Ni foam was also purchased from Sigma Aldrich and used after surface treatment (see experimental section in main text). Deionized water (18.2 M $\Omega$ cm<sup>-2</sup>) was used for the entire nanoassemblies fabrication and electrocatalysis processes. The fabricated Ni<sub>3</sub>Se<sub>4</sub> nanoassemblies was characterized with HR-TEM, (Tecnai<sup>TM</sup> G<sup>2</sup> TF20) working at an accelerating voltage of 200 kV. The Energy Dispersive X-ray Spectroscopy (EDS) analysis was done with the FE-SEM instrument (Oxford) with a separate EDS detector connected to that instrument. The XRD analysis was done with a scanning rate of 5° min<sup>-1</sup> in the 2 $\theta$  range 10-90° using a Bruker X-ray powder diffractometer (XRD) with Cu K<sub>a</sub> radiation ( $\lambda = 0.154$  nm). X-ray photoelectron spectroscopic (XPS) analysis was performed using a Theta Probe AR-XPS system (Thermo Fisher Scientific, UK). Electrochemical analyzer CHI6084c version 12.13 was used for the entire water splitting and related studies. The Ni<sub>3</sub>Se<sub>4</sub> nanoassemblies grown Ni foam 3D electrode was used as working electrode.

## Sample preparation for various characterizations

The fabricated Ni<sub>3</sub>Se<sub>4</sub> nanoassemblies on Ni foam was directly taken for XRD and XPS analyses. TEM samples were prepared by subjecting the fabricated Ni<sub>3</sub>Se<sub>4</sub> nanoassemblies to ultra-sonication for 10 min in 5 mL of Milli pore water during which the Ni<sub>3</sub>Se<sub>4</sub> nanoassemblies water became blackish turbid solution. The solution was then drop casted on carbon coated copper TEM grid after dilution with appropriate amount of Milli pore water and dried at RT in dark and vacuum.

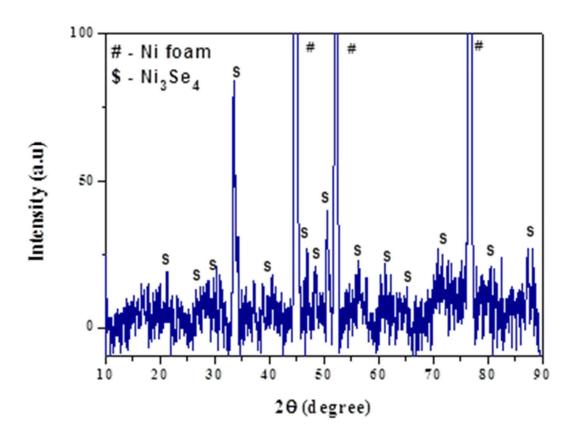


Figure S1: XRD pattern of Ni<sub>3</sub>Se<sub>4</sub> nanoassemblies on Ni foam with decreased Y scale.

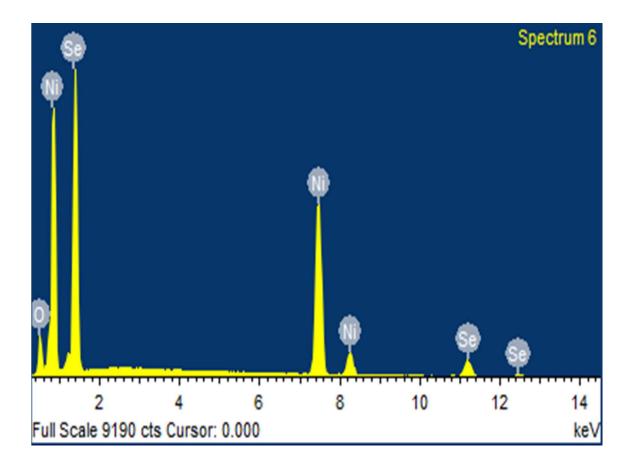


Figure S2: EDS spectrum of Ni<sub>3</sub>Se<sub>4</sub> nanoassemblies on Ni foam.

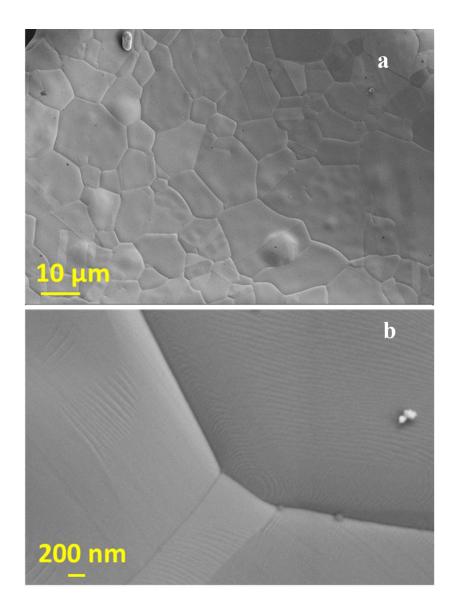


Figure S3: (a-b) FESEM micrographs of Ni foam.

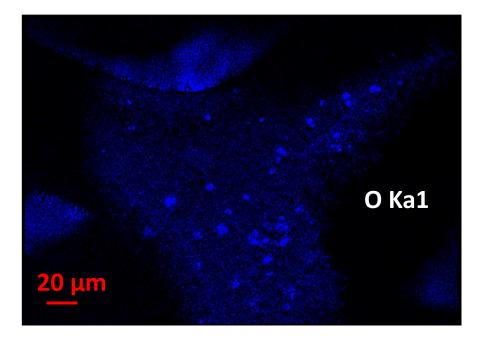


Figure S4: EDS color mapping of  $Ni_3Se_4$  nanoassemblies on Ni foam that shows the presence of O on the surfaces.

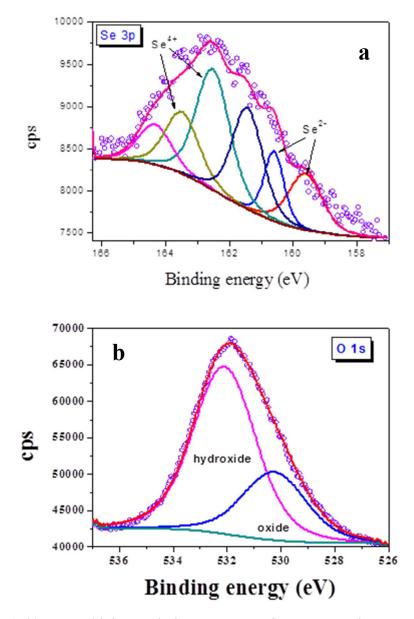
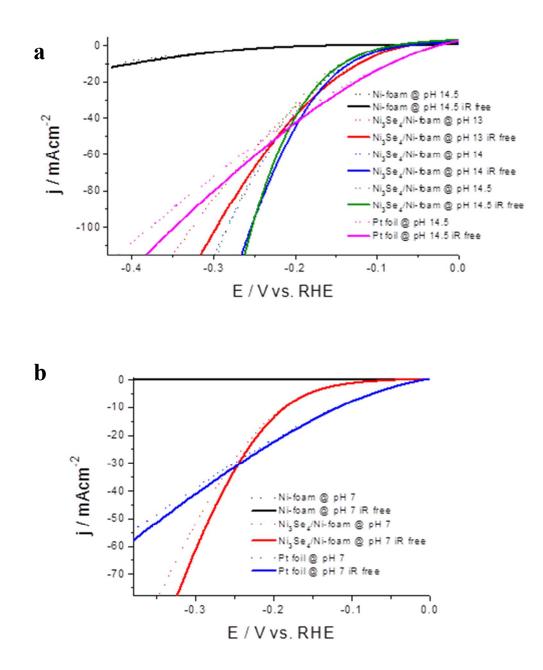
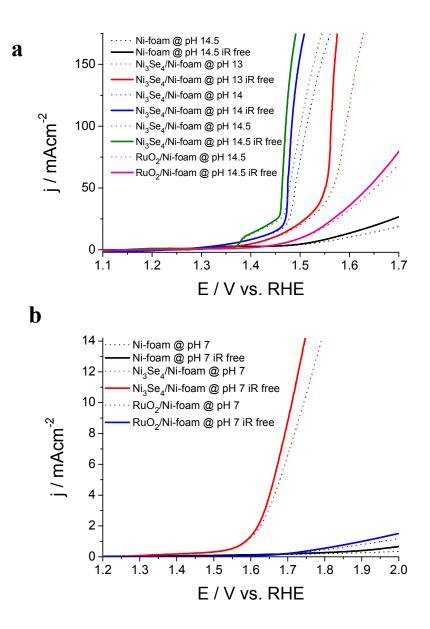


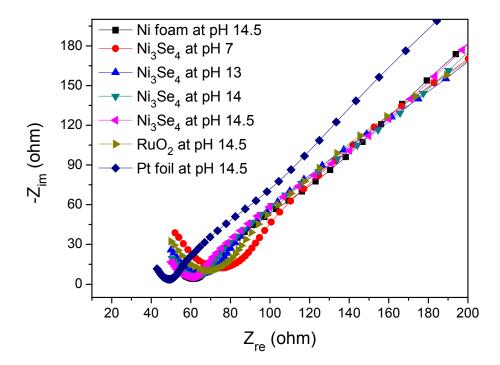
Figure S5: (a-b) XPS high resolution spectra of Se 3p and O 1s state from  $Ni_3Se_4$  nanoassemblies on Ni foam.



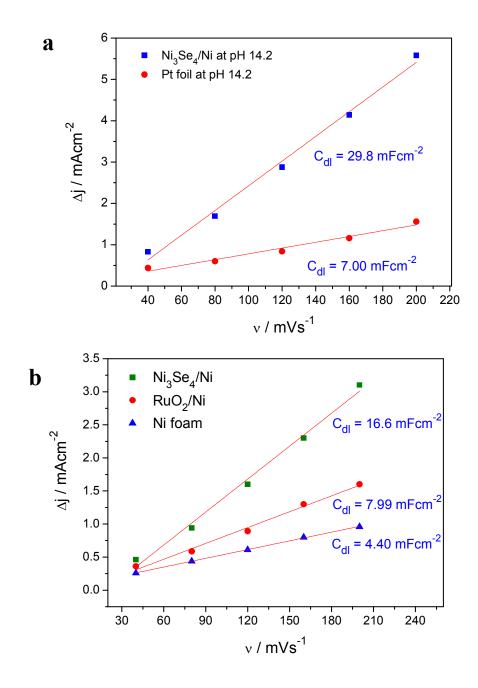
**Figure S6:** (a-b) the iR free and iR uncompensated HER polarization curves acquired at 5 mVs-1 of Ni<sub>3</sub>Se<sub>4</sub>/Ni in alkaline and neutral conditions in comparison with Pt.



**Figure S7:** (a-b) the iR free and iR uncompensated OER polarization curves acquired at 5 mVs-1 of Ni<sub>3</sub>Se<sub>4</sub>/Ni in alkaline and neutral conditions in comparison with RuO<sub>2</sub>/Ni foam.



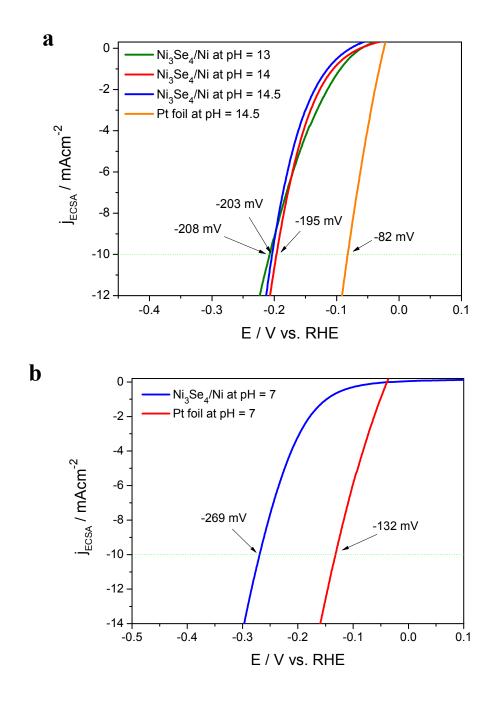
**Figure S8:** The Nyquist plots of Ni<sub>3</sub>Se<sub>4</sub>/Ni. RuO<sub>2</sub>/Ni foam and Pt foil electrode interfaces in alkaline and neutral conditions.



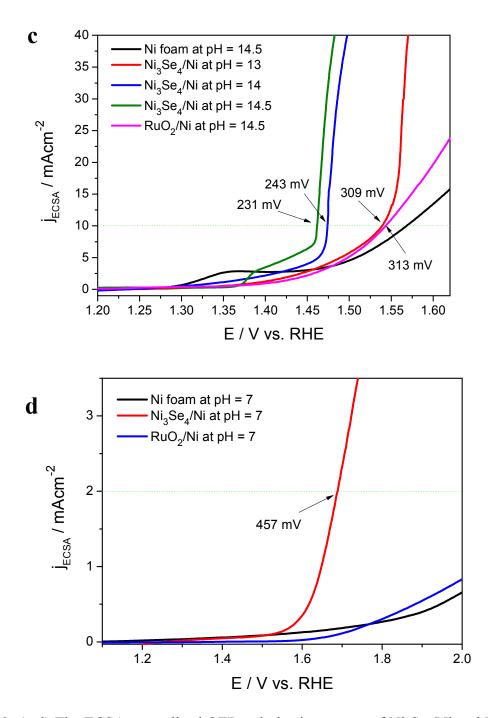
**Figure S9:** (a-b) The plot of the difference in double layer charging currents vs. scan rate at 0.12 V vs. RHE and 1.12 V vs. RHE respectively.

Region	Catalyst	2Cdl (mFcm <sup>-2</sup> )	Relative active area (cm <sup>2</sup> )
(1.12 V vs. RHE)	Ni <sub>3</sub> Se <sub>4</sub> /Ni	16.6	3.772
	RuO <sub>2</sub> /Ni	7.99	1.815
	Ni foam	4.40	1
(0.15 V vs. RHE)	Ni <sub>3</sub> Se <sub>4</sub> /Ni	29.8	4.257
	Pt foil	7.00	1

**Table S1:** The double layer charging currents and the corresponding relative ECSA of $Ni_3Se_4/Ni$ ,  $RuO_2/Ni$  and Pt foil electrodes.



**Figure S10:** (a-b) The ECSA normalized HER polarization curves of Ni<sub>3</sub>Se<sub>4</sub>/Ni and Pt in alkaline and neutral electrolytes.



**Figure S10:** (c-d) The ECSA normalized OER polarization curves of Ni<sub>3</sub>Se<sub>4</sub>/Ni and RuO<sub>2</sub>/Ni in alkaline and neutral electrolytes.



**Figure S11:** A snapshot taken the during operation of two electrode water electrolyser that consists the  $Ni_3Se_4$  nanoassemblies on Ni foam as both anode and cathode while powered with an AAA alkaline battery of optimum voltage output of 1.5 V.

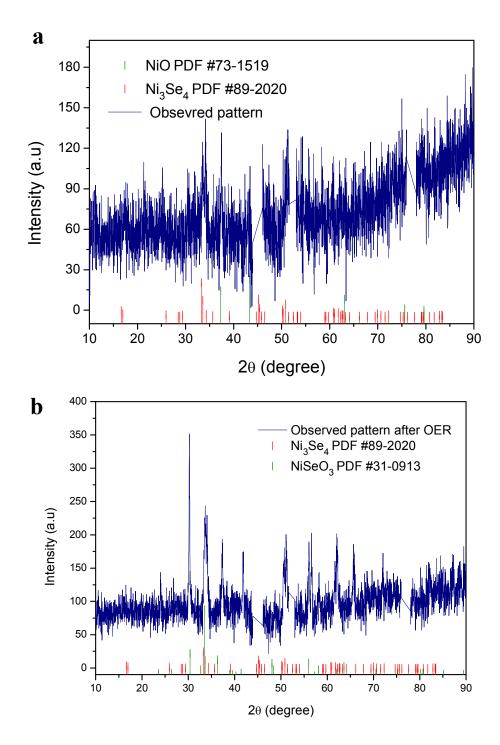
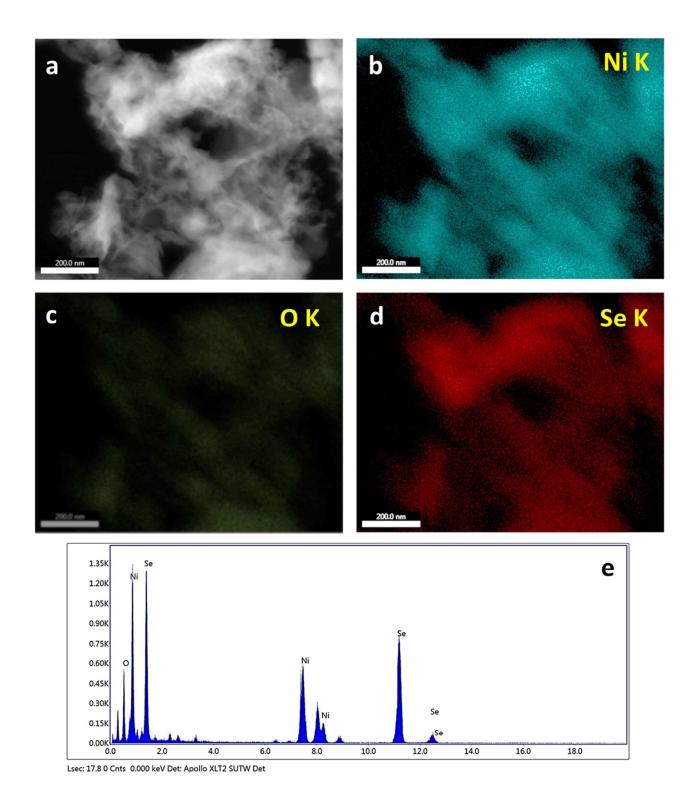
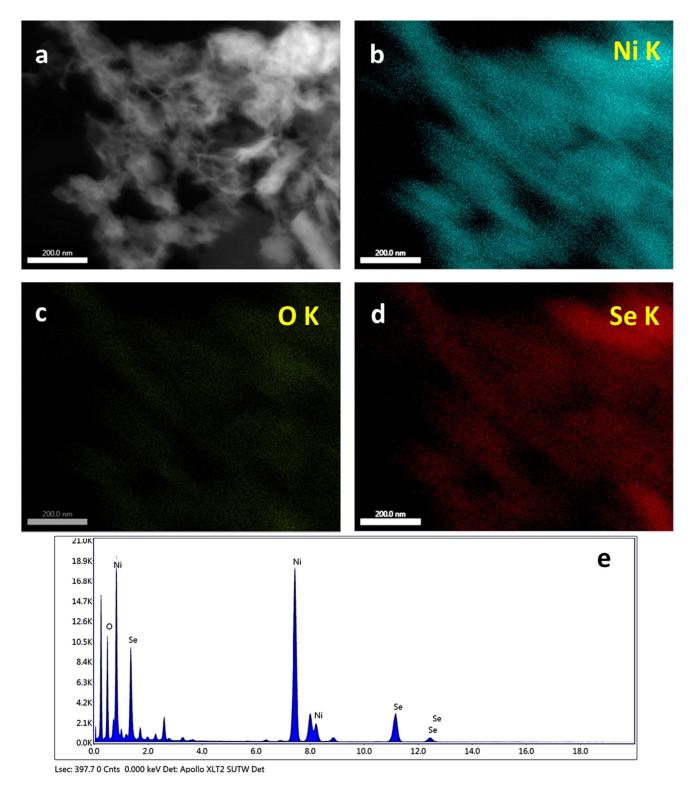


Figure S12: (a-b) XRD patterns of Ni<sub>3</sub>Se<sub>4</sub>/Ni after cathodic and anodic polarizations.



**Figure S13:** (a) HAADF micrograph of  $Ni_3Se_4$  after OER characterizations that shows the area chosen for the elemental mapping. (b-d) color maps of Ni K, O K and Se K respectively in EDAX mode. (e) the corresponding EDAX spectrum.



**Figure S14:** (a) HAADF micrograph of  $Ni_3Se_4$  after HER characterizations that shows the area chosen for the elemental mapping. (b-d) color maps of Ni K, O K and Se K respectively in EDAX mode. (e) the corresponding EDAX spectrum.